

[ABSTRACT]

There is used a polyurethane for polishing layers that can be used as a material of a polishing layer of a polishing pad, the polyurethane including a thermoplastic polyurethane that is a reaction product of a polyurethane raw material including a polymer diol, an organic diisocyanate, and a chain extender, wherein the chain extender contains 50 mass% or more of a first chain extender including a straight-chain carbon backbone having 7 to 12 carbon atoms.